APPLICATION ELEMENTS See APEP chapter 600 concerning utility patent application contents	Assistant Commissioner for Patents Box Patent Application Washington, DC 20231
1. Fee Transmittal Form (e.g. PTO/SB/17) (Submit an original and a duplicate for fee processing)	ACCOMPANYING APPLICATION PARTS
	7. Assignment Papers (cover sheet & document(s))
2. ■ Specification Total Sheets 59	8. Application Data Sheet. See 37 CFR 1.76
JC8	9. 37 C.F.R. §3.73(b) Statement Power of Attorney
Drawing(s) (35 U.S.C. 113) Total Sheets (Formals)	10. ☐ English Translation Document (if applicable)
E.S.	11. Information Disclosure Statement (IDS)/PTO-1449 Copies of IDS Citations (1)
4 ■ Oath or Declaration Total Pages 2	12. □ Preliminary Amendment
a. Newly executed (original)	13. White Advance Serial No. Postcard
b. □ Copy from a prior application (37 C.F.R, §1.63(d)) (for continuation / divisional w/ box 17 completed)	14. Certified Copy of Priority Document(s) (1) (if foreign priority is claimed)
i. DELETION OF INVENTOR(S) Signed statement attached deleting inventor(s) named in the prior application, see 37 C.F.R. §1.63(d)(2) and 1.33(b).	15. Applicant claims small entity status. See 37 CFR 1.27
☐ CD-ROM or CD-R in duplicate, large table or Computer Program (<i>Appendix</i>)	16. ■ Other: Notice of Priority, Statement of Relevancy
6. Nucleotide and/or Amino Acid Sequence Submission	
a. Computer Readable Form (CRF)	
b. Specification or Sequence Listing on:	
ii. □ Paper c. □ Statements verifying identity of above copies	
C. Clatements verifying identity of above copies	
III. If a CONTINUING APPLICATION, check appropriate box, and su	
☐ Continuation ☐ Divisional ☐ Continuation-	
	Group Art Unit:
For CONTINUATION OR DIVISIONAL APPS only: The entire disclosure of the proconsidered a part of the accompanying continuation or divisional application and when a portion has been inadvertently omitted from the submitted application par	to application, from which all out to declaration is supplied under Box 45, is so hereby incorporated by reference. The incorporation can only be relied upon ts.
18. Amend the specification by inserting before the first line the s	entence:
☐ This application is a ☐ Continuation ☐ Division	□ Continuation-in-part (CIP)
of application Serial No. Filed on	
□ Which was published in English	
□ Which was not published in English	
☐ This application claims priority of provisional application Seri	al No. Filed
19. CORRESPONI	DENCE ADDRESS



22850

(703) 413-3000 FACSIMILÉ: (703) 413-2220

Name:	Marvin J. Spivak	Registration No.		24,913
Signature:	6mm Wouse		Date:	6/26/01
Name:	C. Irvin McClelland	Registrati	on No.:	
	Registration Number 21,124			



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

INVENTOR(S) Akira NISHIYAMA, et al.

SERIAL NO:

New Application

FILING DATE: Herewith

FOR:

Ų 0

SEMICONDUCTOR DEVICE AND METHOD OF MANUFACTURING THE SAME

FEE TRANSMITTAL

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

FOR	NUMBER FILED	NUMBER EXTRA	RATE	CALCULATIONS
TOTAL CLAIMS	15 - 20 =	0	× \$18 =	\$0.00
INDEPENDENT CLAIMS	2 - 3 =	0	× \$80 =	\$0.00
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The Commissioner is hereby authorized to charge any additional fees which may be required for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C.

6/26/01

Tel. (703) 413-3000 Fax. (703) 413-2220 (OSMMN 10/00)

Marvin J. Spivak

Registration No. 24.913

C. Irvin McClelland Registration Number 21,124

page <u>1</u> of <u>1</u>

DOCKET NO.: 210313US2SRD

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Akira NISHIYAMA, et al.

SERIAL NO.: NEW APPLICATION

FILED: HEREWITH

FOR: SEMICONDUCTOR DEVICE AND METHOD OF

MANUFACTURING THE SAME

STATEMENT OF RELEVANCY

Reference AW(L. D. Zhang, et al.) on form PTO-1449:

Nanocrystalline TiO₂ was prepared by the hydrothermal method or gas condesation method.

